L Number	Hits 0	Search Text (electrode with formation) and (polymer with insulation) and (coupling with agent) and (catalyst) and (plating electroplating)	DB USPAT; US-PGPUB; EPO; JPO;	Time stamp 2002/12/13 11:23
-	1	(electrode with formation) and (polymer with (dielectric insulative insulation)) and (coupling with agent) and (catalyst) and (plating electroplating)	DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/11/29 15:41
-	36103	(lithography patterning) and ((438/\$) (257/\$)).ccls.	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/11/29 15 42
-	782	((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/29 15:42
-	507	(((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst) and treatment	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/29 15:42
-	295	((((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst) and treatment) and (palladium pd)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/29 15:43
-	241	(((((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst) and treatment) and (palladium pd)) and @ad<=20011005	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/29 15:53
-	3	((((((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst) and treatment) and (palladium pd)) and @ad<=20011005) and (international ibm).as.	USPAT: US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/29 15:54
-	45 357	7and electroplating	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/11/29 15:54
-	28	((((((lithography patterning) and ((438/\$) (257/\$)).ccls.) and catalyst) and treatment) and (palladium pd)) and @ad<=20011005) and electroplating	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/29 15:54
-	186	(438/677).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/13 11:23
-	2	(((438/677).CCLS.) and @ad<=20011005) and ((silane silicon) with coupling)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/13 11:26
-	35	(((438/677).CCLS.) and @ad<=20011005) and cataly\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/13 11:39

-	132065	438/\$.ccls.	USPAT; US-PGPUB;	2002/12/13 11:40
			EPO; JPO; DERWENT; IBM TDB	
-	208	438/\$ ccls. and ((silicon silane) with coupling with agent)	USPAT; US-PGPUB; EPO; JPO;	2002/12/13 11:45
-	6	(438/\$.ccls. and ((silicon silane) with coupling with agent)) and ((palladium pd) with catalyst)	DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/12/13 11:51
-	8	("5272111" "5525204" "5674787" "5824599" "5830563" "6060176" "6197688" "6251781").PN.	IBM_TDB USPAT	2002/12/13 11:44
-	91	216/\$.ccls. and ((silicon silane) with coupling with agent)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/13 11:50
-	26	(438/\$.ccls. and ((silicon silane) with coupling with agent)) and (solution with cataly\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/13 11:47
-	9	(438/\$.ccls. and ((silicon silane) with coupling with agent)) and ((palladium pd) with cataly\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/13 11:51
-	4	(216/\$.ccls. and ((silicon silane) with coupling with agent)) and ((palladium pd) with cataly\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/13 11:51
-	171	((438/677).CCLS.) and @ad<=20011005	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/13 11:52
-	5 7	5604153.URPN. ("4460618" "5091210" "5179042" "5180687" "5196372" "5208187" "5217756").PN.	USPAT USPAT	2002/12/14 11:17 2002/12/14 11:18
-		5569628.URPN. ("4592800" "5091103" "5312776" "5466389" "5514478" "5538921" "5569628" "5648324" "5665688" "5780406" "5798323" "5817610").PN.	USPAT USPAT	2002/12/14 11:45 2002/12/14 11:47
-		"5312776".PN. treat\$3 with (insulation insulative dielectric) and "coupling agent" and (cataly\$3 with solution)	USPAT USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 11:47 2002/12/14 12:08
-	2	("5569628").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 12:45
-	2391	((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 12:46

-	163	(((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and (silane silicon coupl\$3) with (agent solution)	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/12/14 12:59
-	25	((((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and (silane silicon coupl\$3) with (agent solution)) and cataly\$3	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/12/14 12:57
-	0	((((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and (silane silicon coupl\$3) with (agent solution)) and selective with deposition with catalyst	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 12:58
-	0	((((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and (silane silicon coupl\$3) with (agent solution)) and selective with deposition	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 12:58
-	0	(((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and selective with deposition with catalyst	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 12:58
-	6	((((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and (silane silicon coupl\$3) with (agent solution)) and "coupling agent"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 13:29
-	8	("5272111" "5525204" "5674787" "5824599" "5830563"	USPAT	2002/12/14 13:20
-	18	"6060176" "6197688" "6251781").PN. (((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and catalyst with solution and palladium	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:30
-	19	(((438/627) or (438/628) or (438/641) or (438/643) or (438/644) or (438/678) or (438/800) or (438/942)).CCLS.) and catalyst with solution and (palladium pd)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:35
-	559	(((438/\$) (257/\$)).ccls.) and "coupling agent"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:37
-	7	((((438/\$) (257/\$)).ccls.) and "coupling agent") and catalyst with treatment	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:47
	6	(("6495005") or ("5925259") or ("5817242") or ("6391691")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:51
	710	((andry flake michel tsujimura).inv.) and ((ibm international).as.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 13:54
	0	(((andry flake michel tsujimura).inv.) and ((ibm international).as.)) and catlyst and "coupling agent"	USPAT, US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:53
1 1 12 4	40/45/06			

-	6	(((andry flake michel tsujimura).inv.) and ((ibm	USPAT;	2002/12/14 13:54
		international).as.)) and catalyst and "coupling agent"	US-PGPUB; EPO; JPO; DERWENT;	2002/12/14 15:54
-	175	((andry flake michel tsujimura).inv.) and ((ibm).as.)	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/12/14 13:56
-	0	(((andry flake michel tsujimura).inv.) and ((ibm).as.)) and "coupling agent"	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT;	2002/12/14 13:55
-	1	(((andry flake michel tsujimura).inv.) and ((ibm).as.)) and catalyst	IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 13:55
-	671	((andry flake michel tsujimura).inv.) and ((ibm (international with machines).as.))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 13:57
-	15	(((andry flake michel tsujimura).inv.) and ((ibm (international with machines).as.))) and catalyst	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 14:05
-	251200	((438/\$) (257/\$).ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 14:07
-	268205	((438/\$) (257/\$)).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 14:07
-	88	(((438/\$) (257/\$)).ccls.) and insulation with functional	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 14:08
-	20	((((438/\$) (257/\$)).ccls.) and insulation with functional) and coupling	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 14:10
-	3	((((438/\$) (257/\$)).ccls.) and insulation with functional) and catalyst	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 14:12
-	1666	"coupling agent" with "catalyst"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 17:16
-	31	("coupling agent" with "catalyst") and "conductive layer"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/14 17:16
-	9	("4548867" "4946903" "5051312" "5079600" "5206309" "5266309" "5342737" "5389496" "5500315").PN.	USPAT	2002/12/14 17:22

_	5	5500315.URPN,	LICDAT	0000/40/44 47 05
-	215061	"427"	USPAT USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 17:25 2002/12/14 17:42
-	3179	((427/98) or (427/301) or (427/304) or (427/305) or (427/306)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 17:42
-	46	(((427/98) or (427/301) or (427/304) or (427/305) or (427/306)).CCLS.) and "coupling agent" and "catalyst"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 17:43
-	30	((((427/98) or (427/301) or (427/304) or (427/305) or (427/306)).CCLS.) and "coupling agent" and "catalyst") and (electroplating electroless)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/14 17:44
-	95	5079600.URPN.	USPAT	2002/12/14 17:55